

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L11	744040	(heat\$3 anneal\$3 thermal) with control\$4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/12/10 11:16
L12	69623	11 with (even\$3 constant consisten\$2 uniform\$2)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/12/10 11:20
L13	259	12 same ((wafer substrate) with (separat\$4 cleav\$3 detach\$5 split\$4 divid\$3 break\$3))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/12/10 11:19
L14	0	13 and ((porous porosity) same implant\$6)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/12/10 11:15